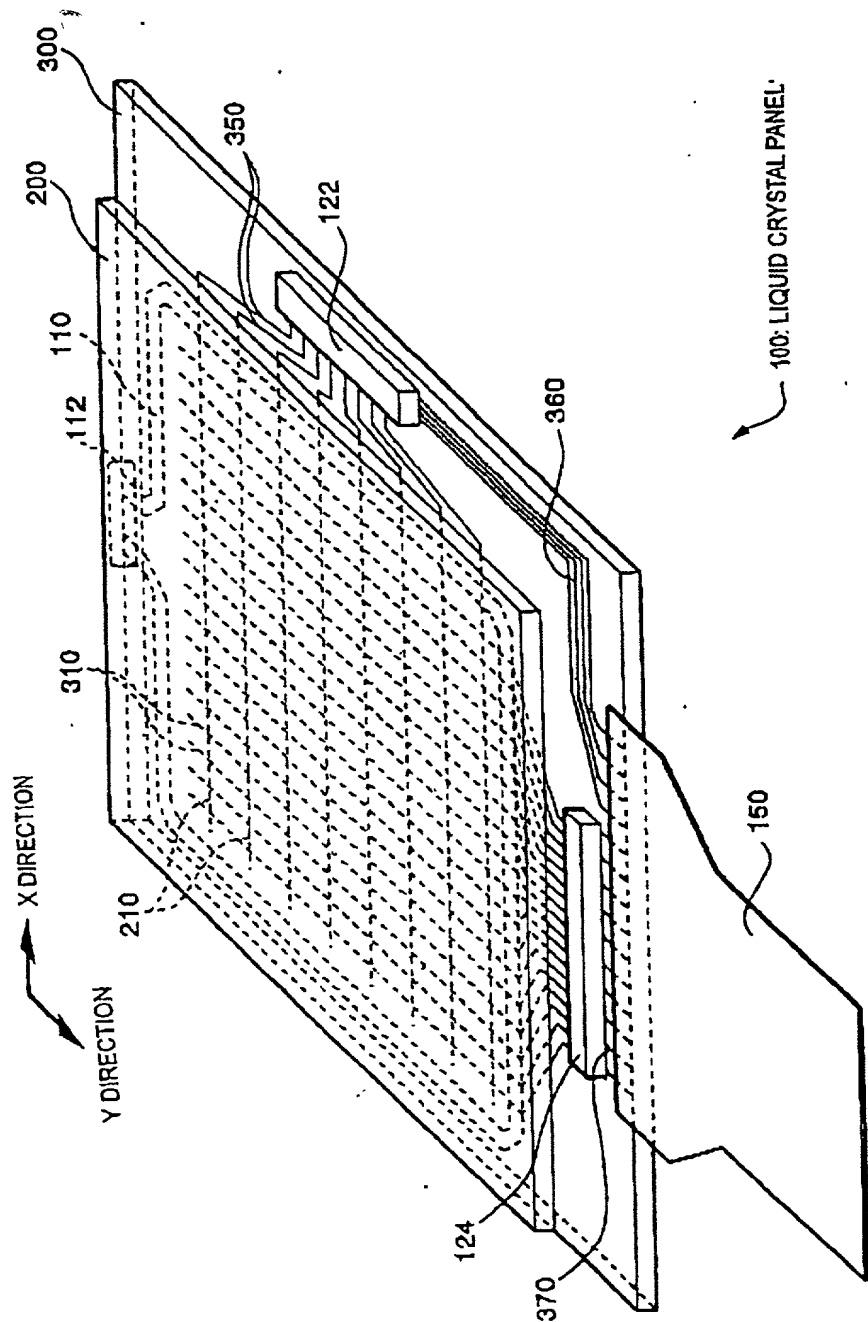
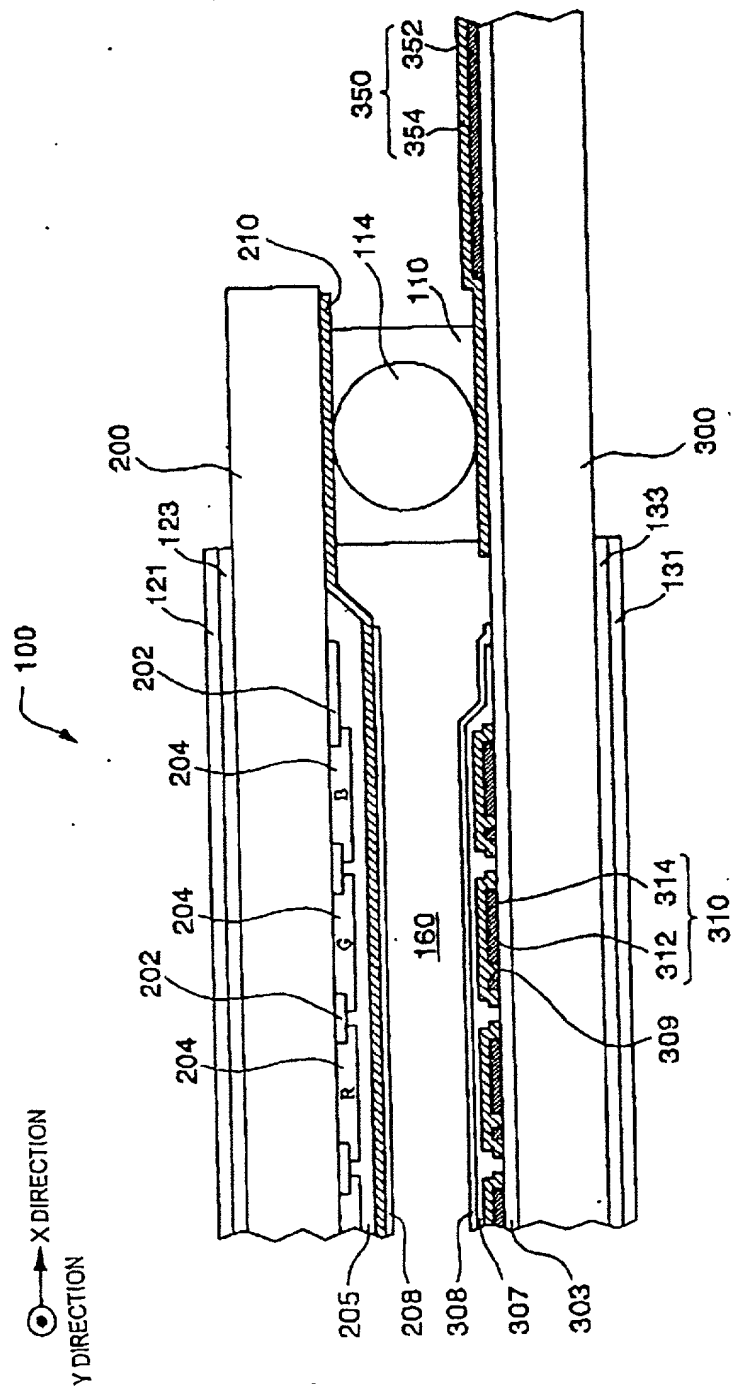


[Fig. 1]



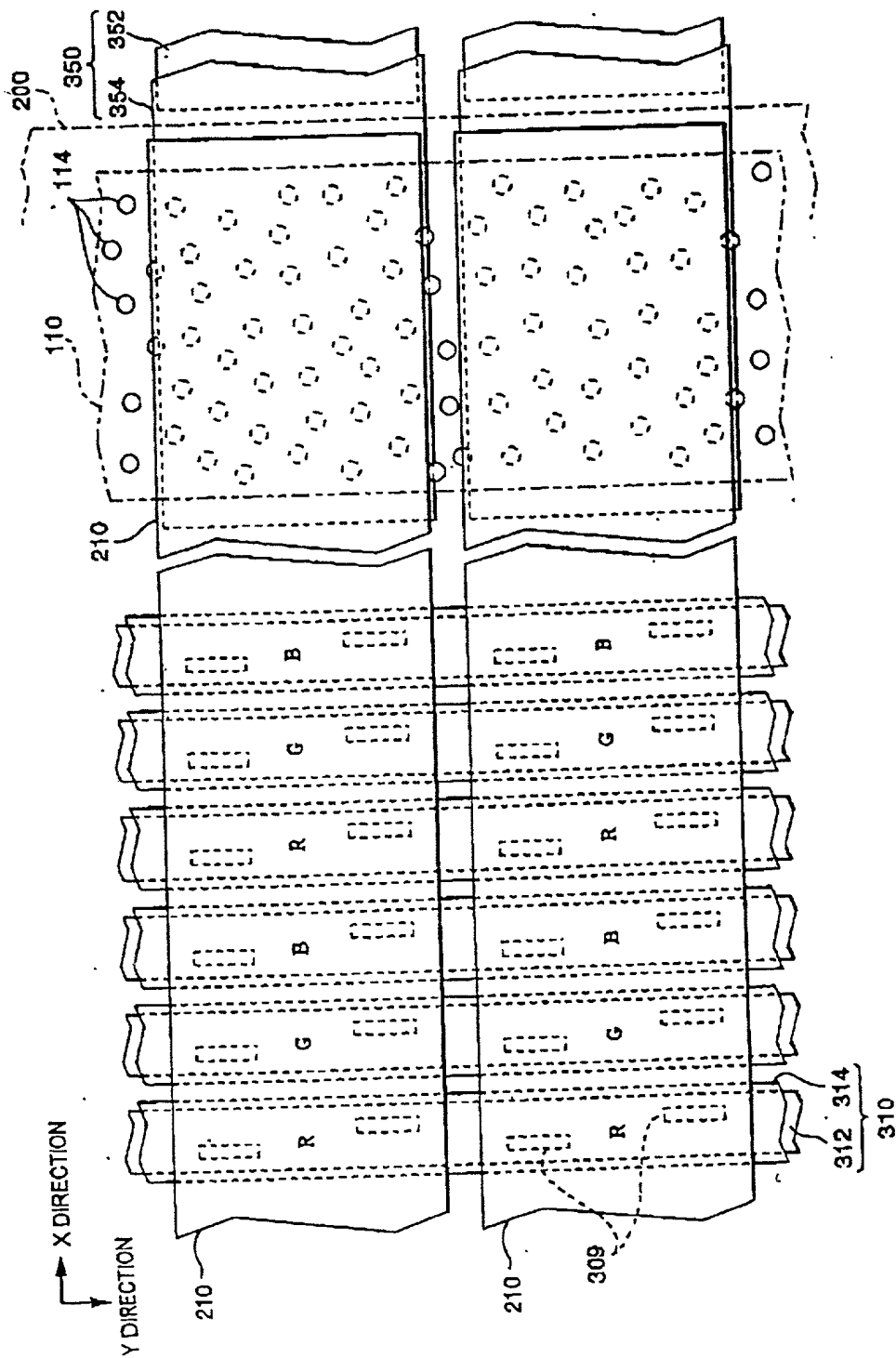
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[Fig. 2]



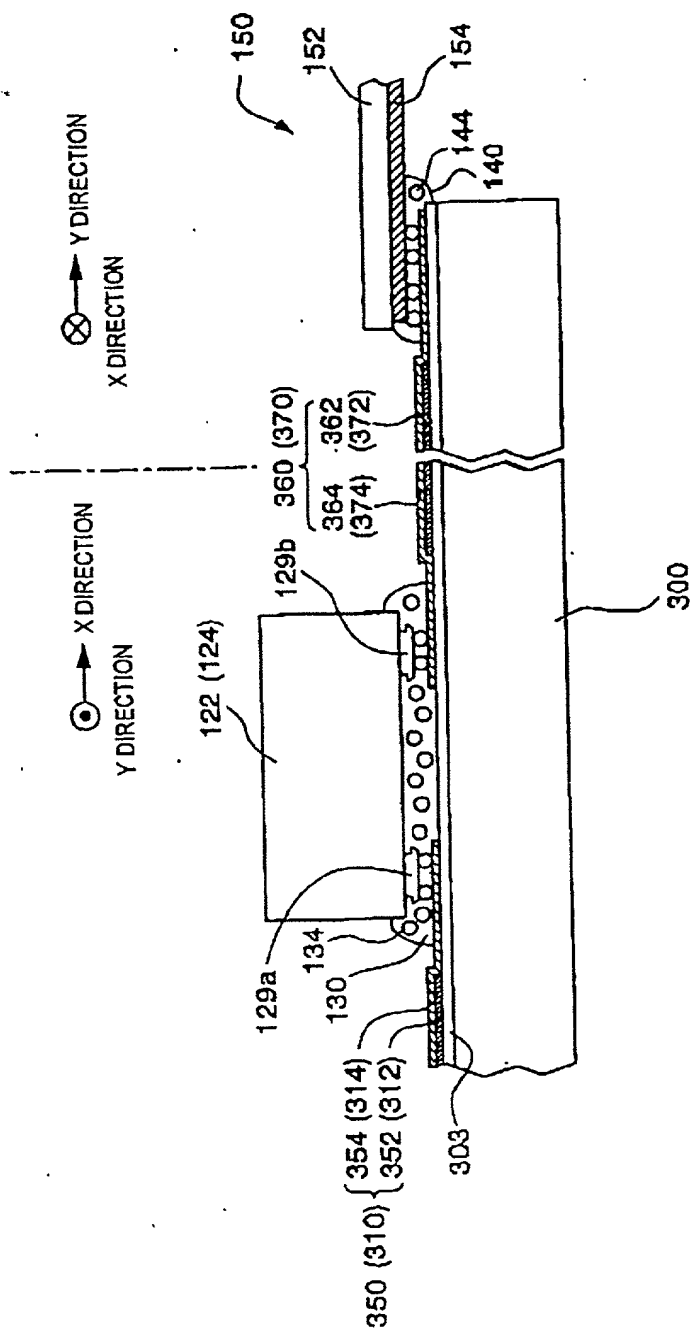
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[Fig. 3]



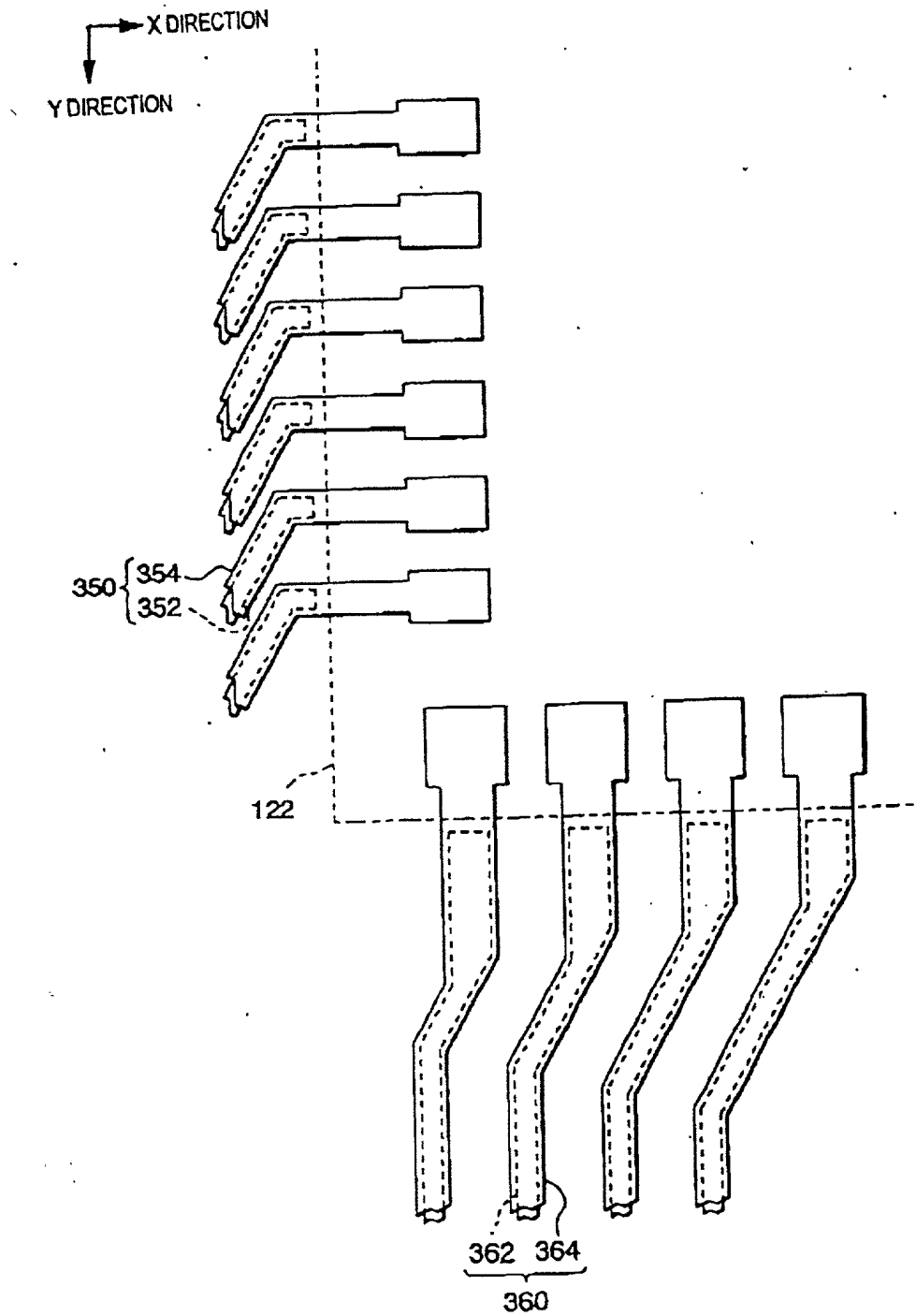
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[Fig. 4]



[Fig. 5]

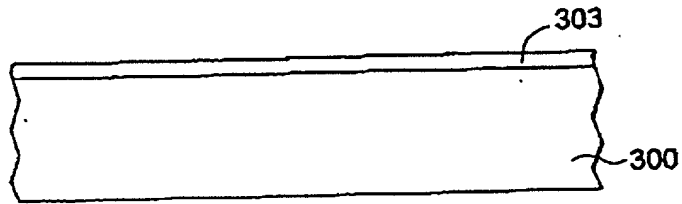
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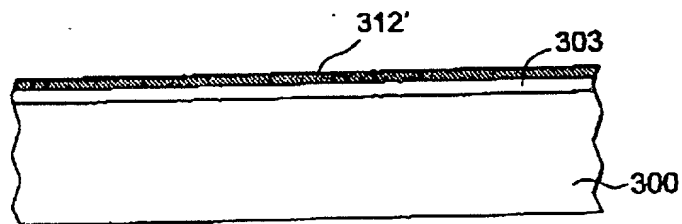
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[Fig. 6]

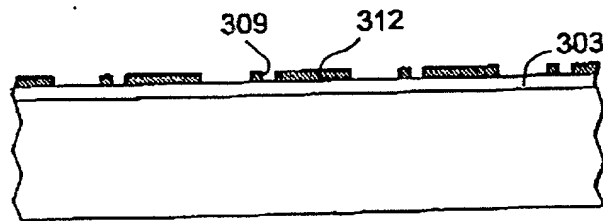
(a)



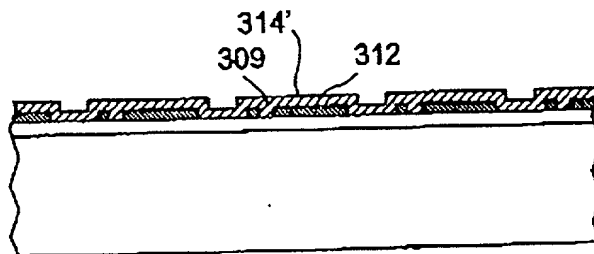
(b)



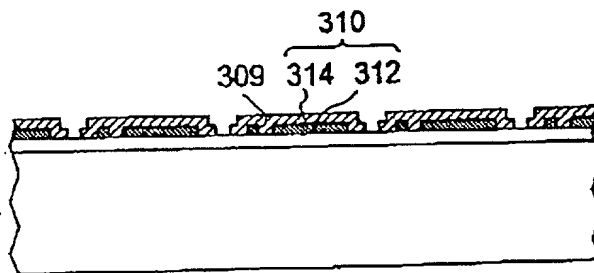
(c)



(d)

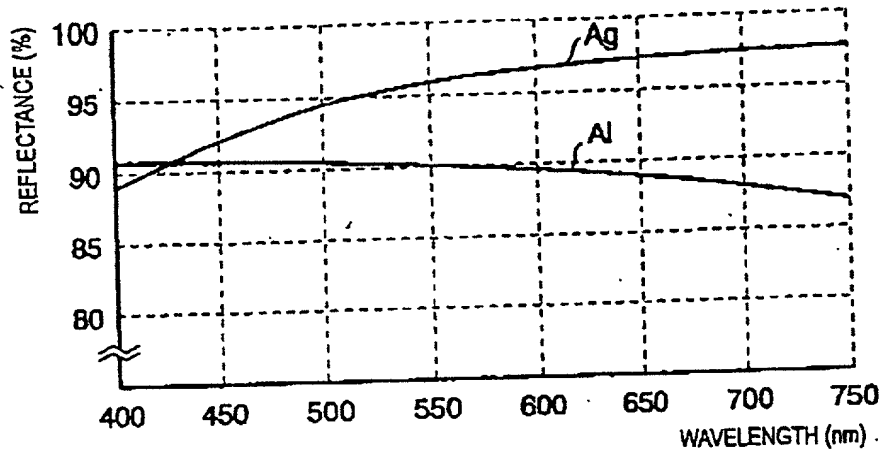


(e)



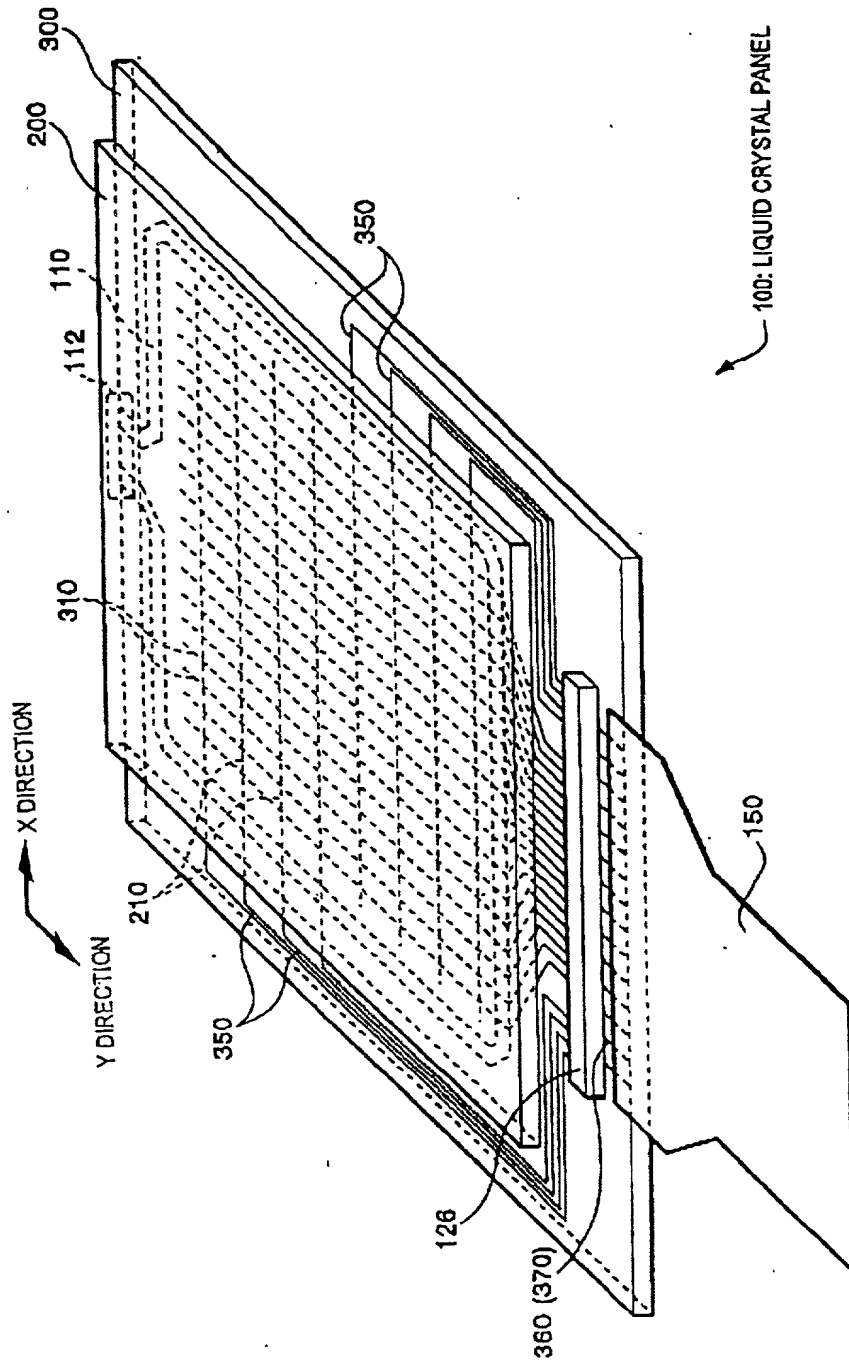
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[Fig. 7]



[Fig. 8]

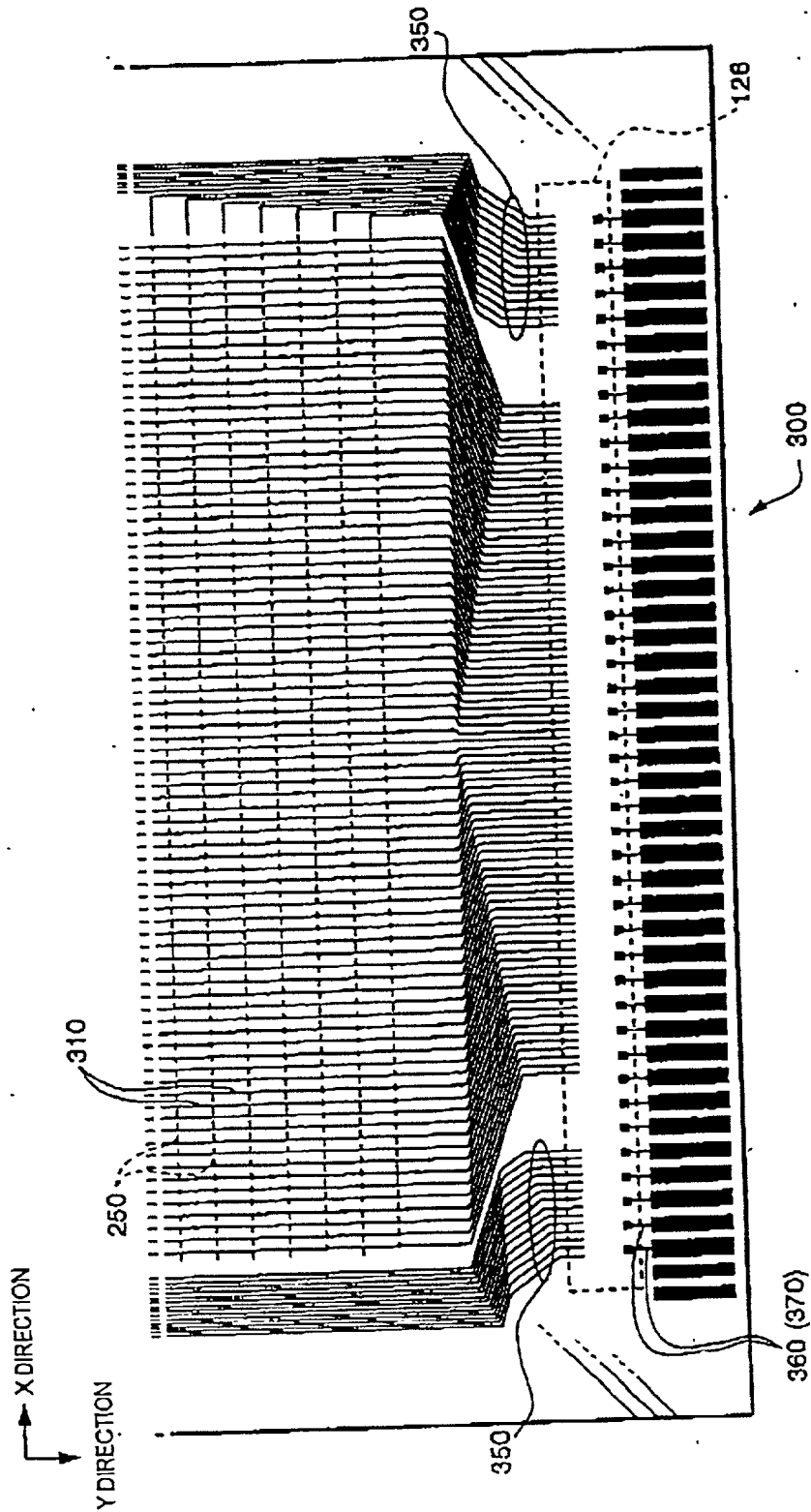
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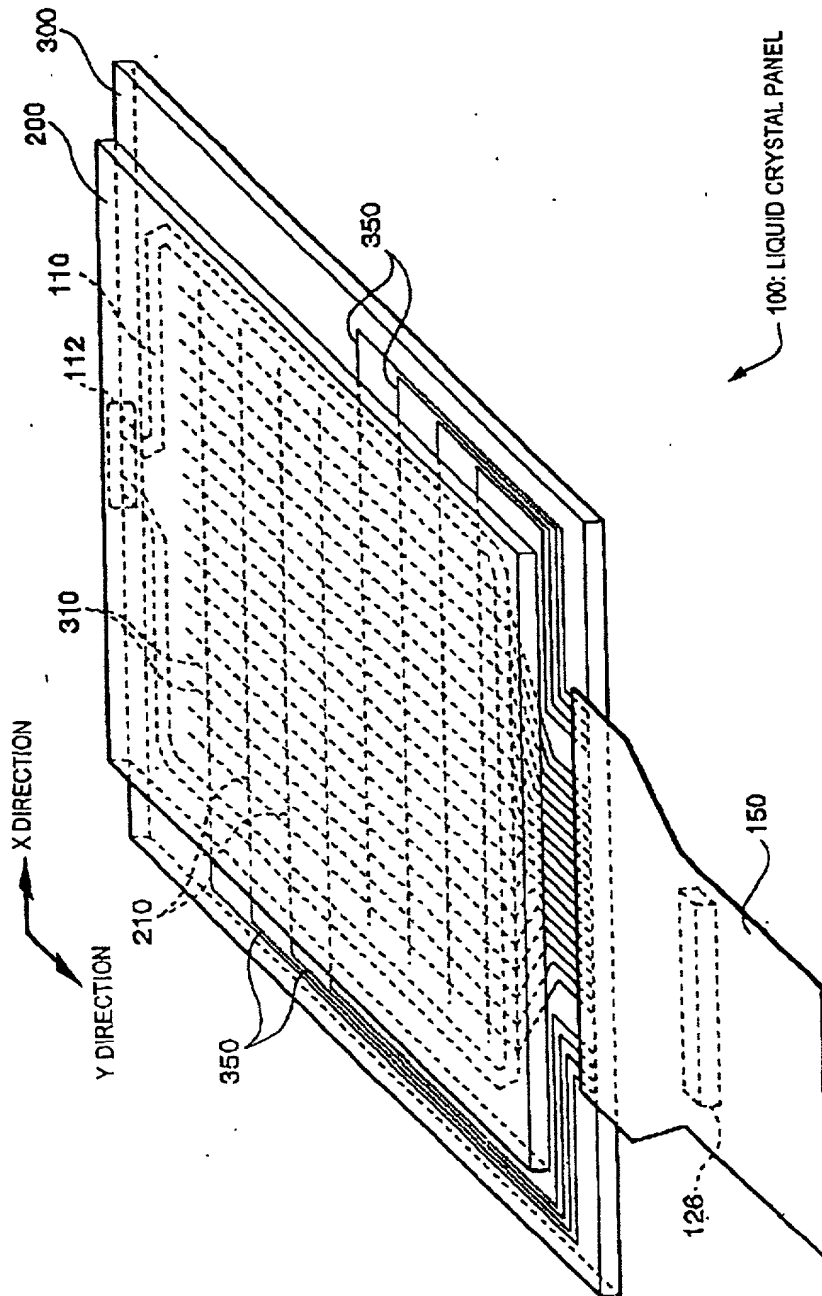
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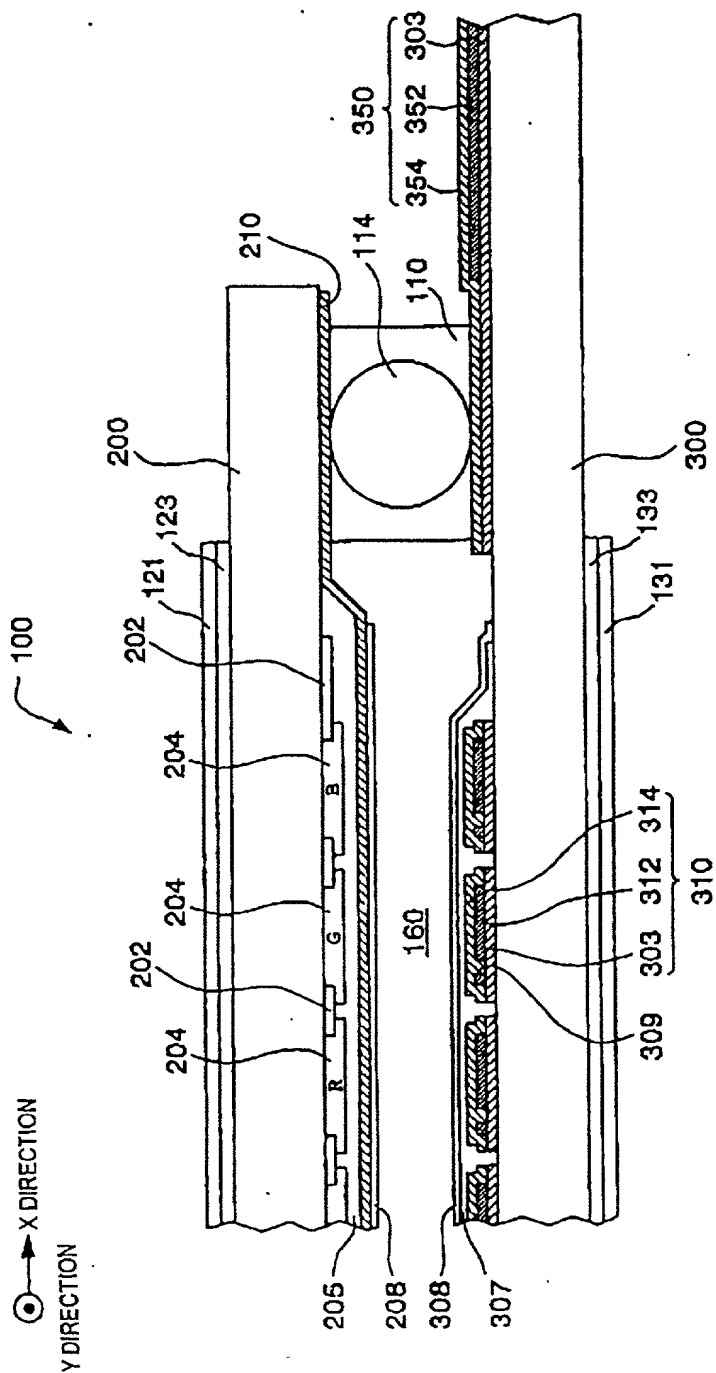
[Fig. 9]

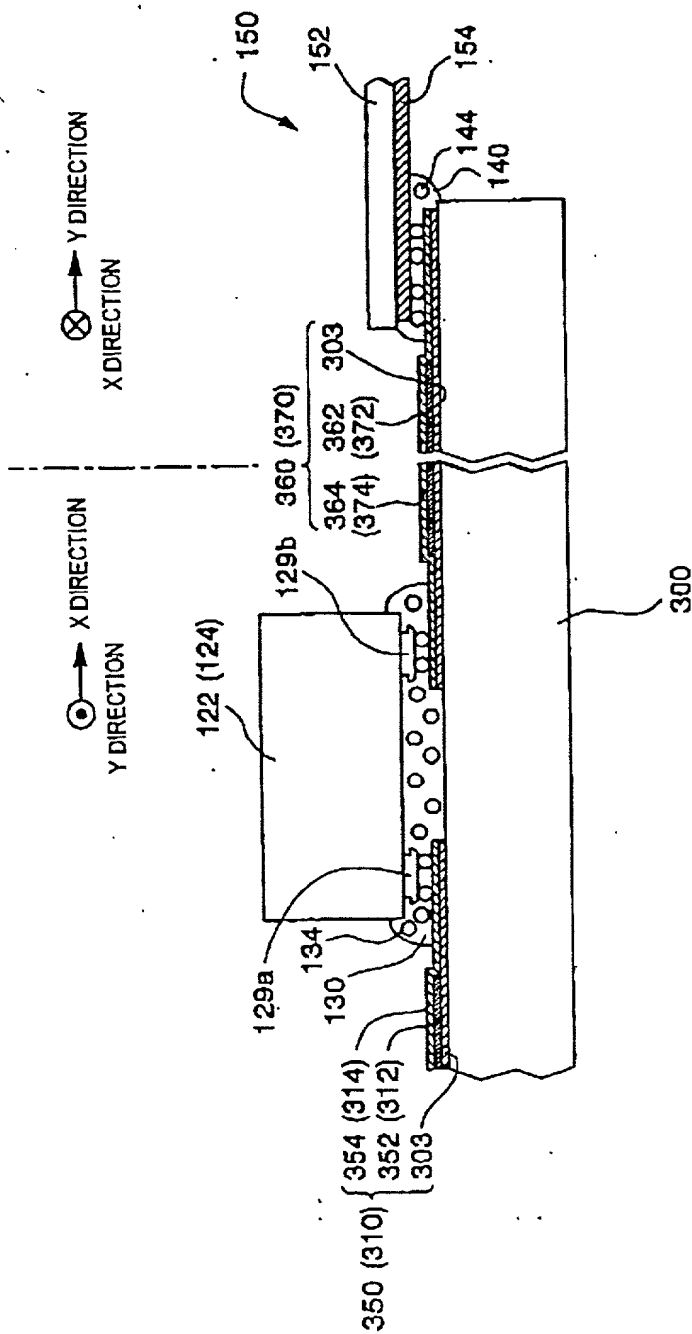


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[Fig. 10]



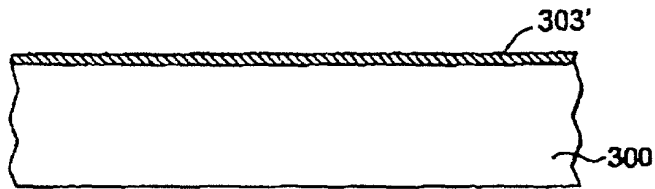




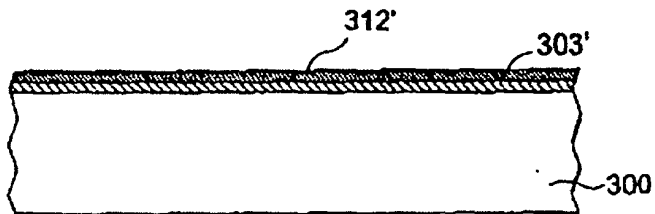
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[Fig. 13]

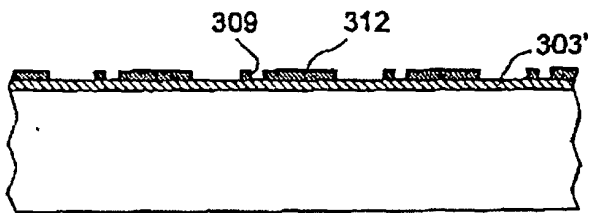
(a)



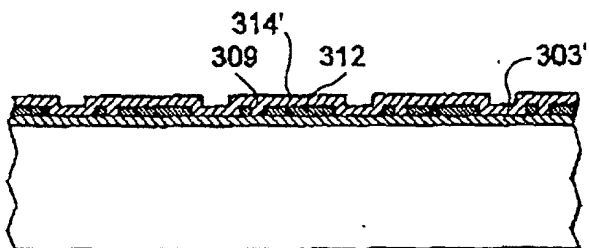
(b)



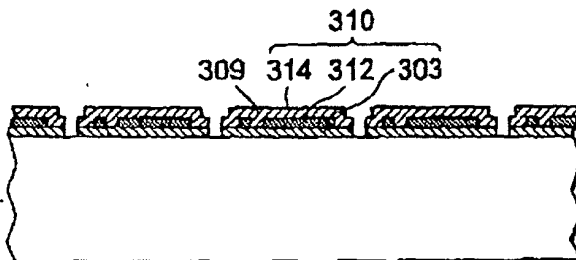
(c)



(d)

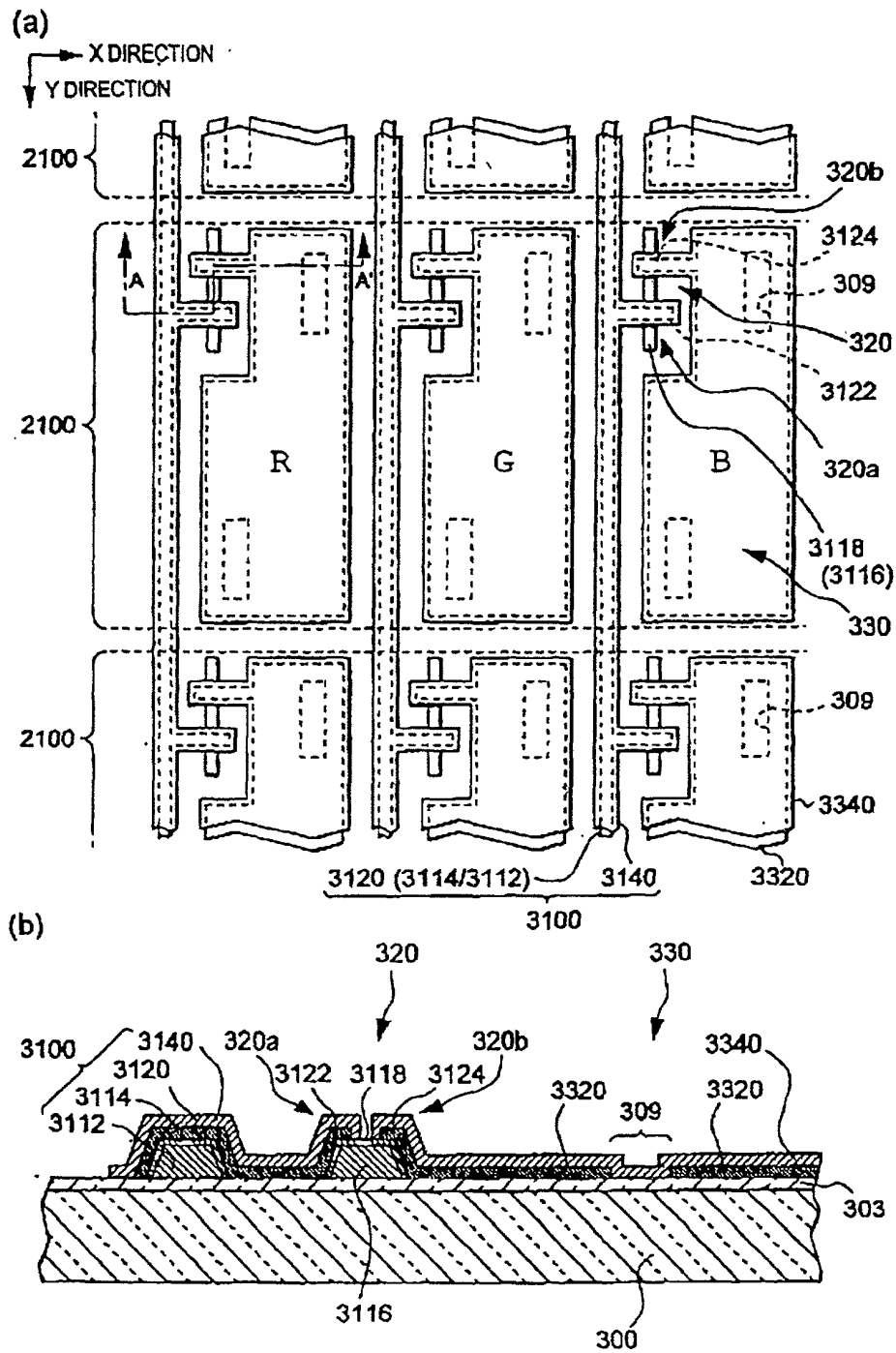


(e)



[Fig. 14]

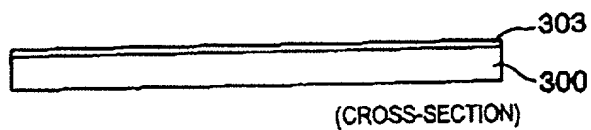
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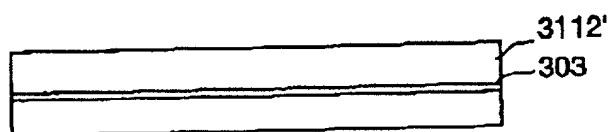
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[Fig. 15]

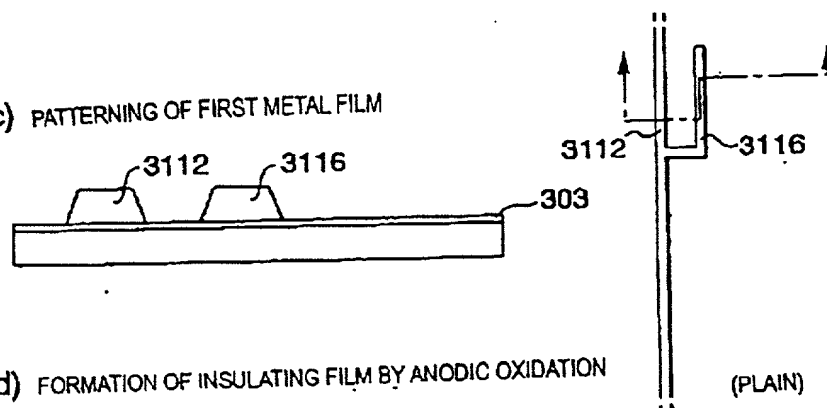
(a) UNDERLYING FILM DEPOSITION



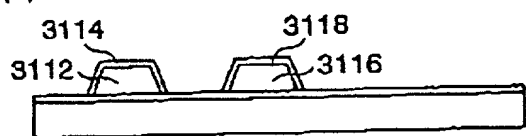
(b) FIRST METAL FILM DEPOSITION



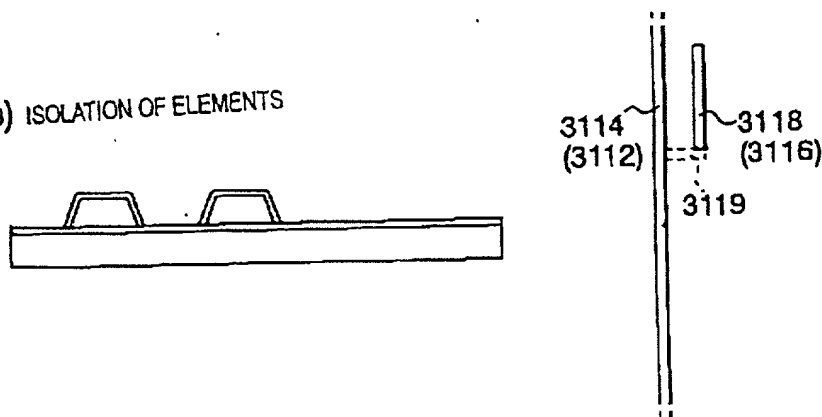
(c) PATTERNING OF FIRST METAL FILM



(d) FORMATION OF INSULATING FILM BY ANODIC OXIDATION



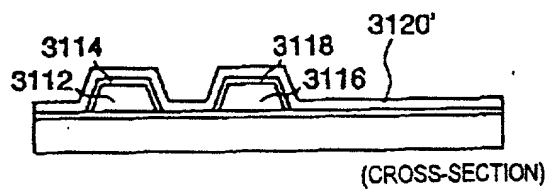
(e) ISOLATION OF ELEMENTS



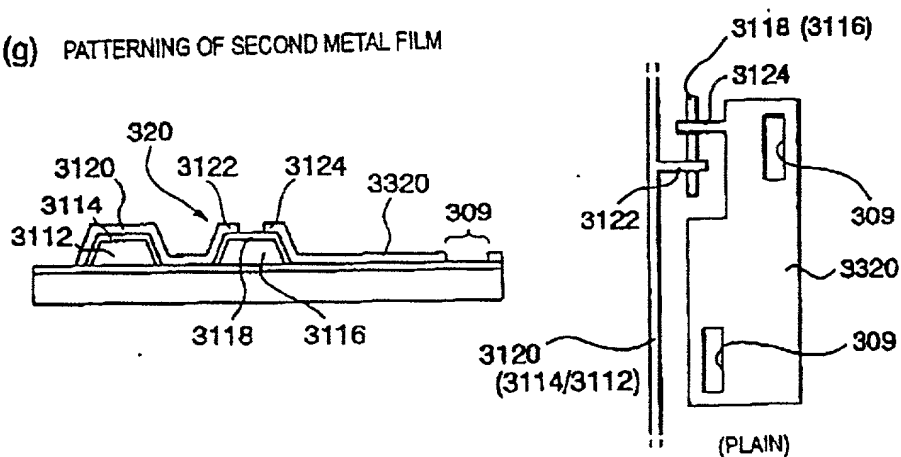
[Fig. 16]

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(f) SECOND METAL FILM (SILVER ALLOY) DEPOSITION



(g) PATTERNING OF SECOND METAL FILM

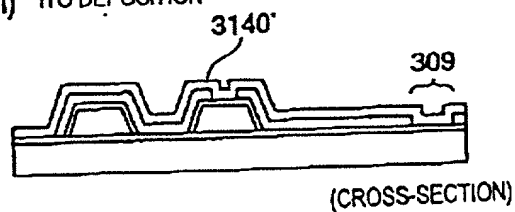




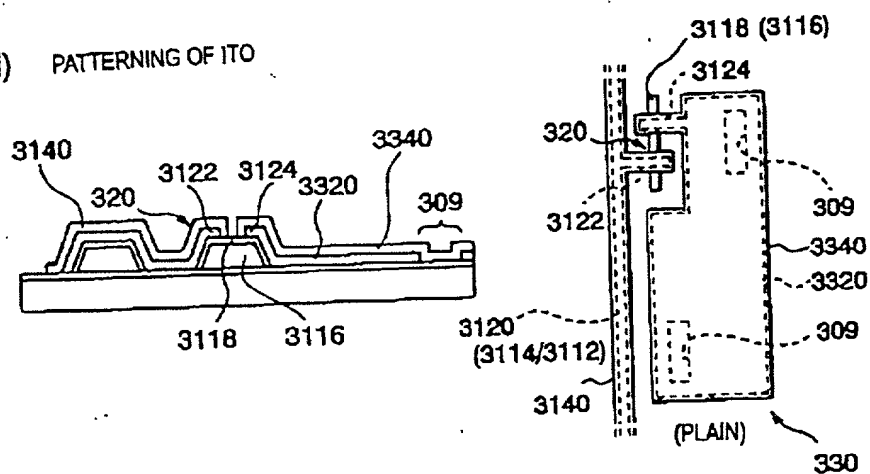
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[Fig. 17]

(h) ITO DEPOSITION

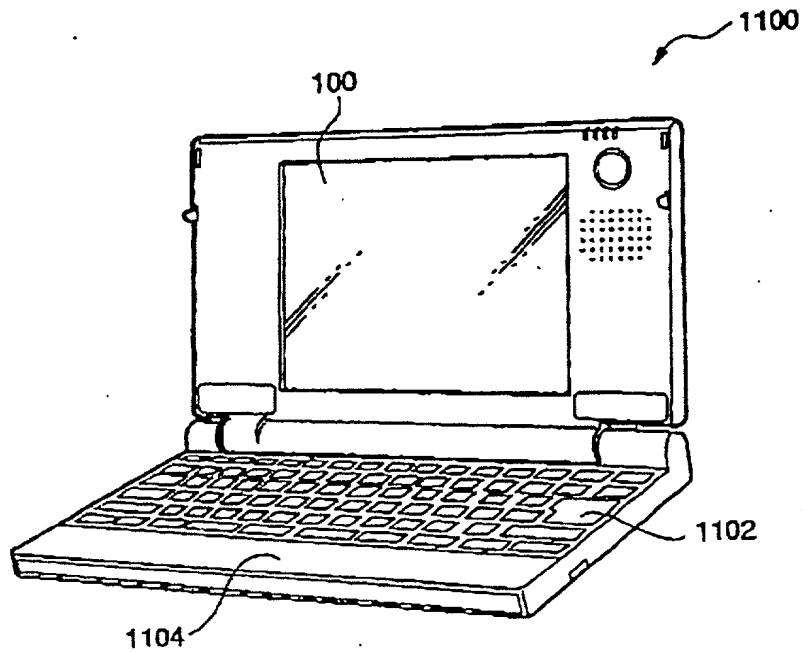


(i) PATTERNING OF ITO

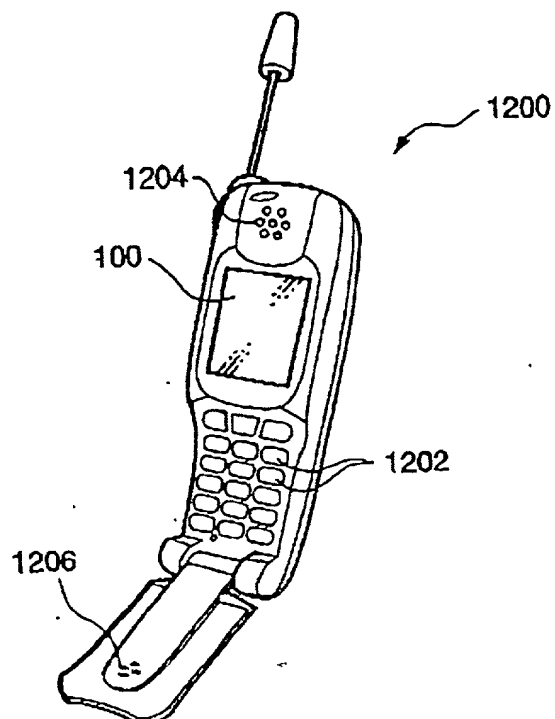


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[Fig. 18]



[Fig. 19]



[Fig. 20]

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